Amendment dated PROPOSED

Reply to Office Action of February 27, 2006

## Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

## **Listing of Claims:**

(Currently Amended) A protective film of a plasma display panel, comprising:

 a main component comprising magnesium oxide (MgO); and
 an addition of silicon (Si), wherein less than 500 wt. ppm and greater than 150
 wt.ppm of silicon is added to the main component to produce said protective film.

- 2. (Currently Amended) The protective film as claimed in claim 1, wherein said addition of silicon is about 20 greater than 150 wt. ppm to and at most 300 wt. ppm.
- 3. (Currently Amended) The protective film as claimed in claim 1, wherein the protective film further comprises:

calcium (Ca) less than 50 wt. ppm;

iron (Fe) less than 50 wt. ppm; and

aluminum (Al) less than 250 wt. ppm.

- 4. (Currently Amended) The protective film as claimed in claim 1, wherein said protective film has about 300 wt. ppm of silicon.
  - 5-10. (Canceled)
- 11. (Previously Presented) The protective film as claimed in claim 1, wherein the addition of silicon compensates for secondary electron emission characteristics deteriorated by crystalline defects and impurities.
- 12. (Currently Amended) The protective film as claimed in claim 1, wherein the addition of silicon reduces is a predetermined amount required to reduce a jitter value within the plasma display panel during address to within a predetermined range.
  - 13-14. (Canceled)
  - 15. (Currently Amended) A plasma display panel, comprising: an upper substrate;
    - a lower substrate across from the upper substrate;
    - a plurality of electrodes on the upper substrate;

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a protective film on the upper substrate layer; and

a plurality of electrodes on the lower substrate, wherein said protective film comprises a main component of magnesium oxide and an addition of a predetermined amount of silicon, wherein greater than 150 wt.ppm and less than 500 wt.ppm of silicon is added to the main component to produce said protective film.

16-17. (Canceled)

- 18. (Currently Amended) The plasma display panel as claimed in claim 15, wherein said protective film comprises an addition of silicon of about 20 to at most 300 wt.ppm.
- 19. (Currently Amended) The plasma display panel as claimed in claim 15, wherein the protective film further comprises:

calcium (Ca) less than 50 wt.ppm;

iron (Fe) less than 50 wt.ppm; and

aluminum (Al) less than 250 wt.ppm.

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- 20. (Previously Presented) The plasma display panel as claimed in claim 15, further comprising a discharge gas between the upper and lower substrates, wherein said discharge gas contains 5 volume % Xenon or more.
- 21. (Currently Amended) The protective film as claimed in claim 1, wherein the protective film further comprises:

nickel (Ni) less than 5 <u>wt.</u> ppm; sodium (Na) less than 5 <u>wt.</u> ppm; and potassium (K) less than 5 <u>wt.</u> ppm.

22. (Currently Amended) The protective film as claimed in claim 3, wherein the protective film further comprises:

nickel (Ni) less than 5 <u>wt.</u> ppm; sodium (Na) less than 5 <u>wt.</u> ppm; and potassium (K) less than 5 <u>wt.</u> ppm.

23-24. (Canceled)

25. (Currently Amended) The plasma display panel as claimed in claim 15, wherein the protective film further comprises:

nickel (Ni) less than 5 <u>wt.ppm</u>; sodium (Na) less than 5 <u>wt.ppm</u>; and potassium (K) less than 5 <u>wt.ppm</u>.

26. (Previously Presented) The plasma display panel as claimed in claim 19, wherein the protective film further comprises:

an upper dielectric layer on the upper substrate.

- 27. (Currently Amended) A protective film of a plasma display panel, comprising: magnesium oxide (MgO); and silicon (Si), wherein said protective film has about 300 wt. ppm of silicon.
- 28. (Canceled)